

Transaction Information

Wafer Size	200 mm
Fab Section	Lithography

General Product Information

Vendor Supplier	NIKON
Model	NSR-2205EX14C
Vintage	2000
Asset Description	NIKON DUV STEPPER
Software Version	MCSV E3.42, OCSV E3.42, Tool: 4.01-EX5100, Base Kit: BASEEX502-0003F, Wafer Loader: WLDR8_022-V340B, Reticle Loader: RLDR8SF12-V280A
CIM	SECS
Process	Lithography Exposure Step and Repeat Stepper

Hardware Configuration

System Type	Description	Quantity
Main System	Cymer Laser	1
Options System		
Main System	Wafer Loader Type 3	1
Main System	NSR Main Body	1
Others		
Main System	Temperature Controller Rack	1
Handler System	Wafer Loader Type 3	1
Main System	Control Rack	1
Factory Interface	SMIF	2

Excluded Items List (Pumps, Chillers & Abatement are all excluded)

Description	Quantity
Control Rack cover missing	1
LSA He-Ne Laser faulty	1
Center Table assembly faulty	1
Temperature Controller Rack cover missing	1
MLTC Pump joint leak	1
Wafer Stage WY Linear Motor Controller faulty	1